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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/504,660	02/14/2000	William E. Hoke	07206-047001	8160	
22494 7	590 10/17/2003		EXAM	EXAMINER	
•	WLEY & MOFFORI	KANG, DO	KANG, DONGHEE		
SUITE 101 275 TURNPIK	E STREET		ART UNIT	PAPER NUMBER	
CANTON, MA 02021-2310			2811	11	

DATE MAILED: 10/17/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

				FATS			
,		Application No.	Applicant(s)				
Office Action Summary		09/504,660	HOKE ET AL.				
		Examiner	Art Unit	 ,,			
		Donghee Kang	2811				
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet wit	h the correspondenc addres	SS			
THE - Extermited after - If the - If NC - Failure - Any I	ORTENED STATUTORY PERIOD FOR REPL'MAILING DATE OF THIS COMMUNICATION. SIX (6) MONTHS from the mailing date of this communication. Period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute eply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a re y within the statutory minimum of thirty vill apply and will expire SIX (6) MONT , cause the application to become AB	ply be timely filed r (30) days will be considered timely. I'HS from the mailing date of this commu	inication.			
1)	Responsive to communication(s) filed on 15 S	Sentember 2003 .					
2a)□	· · · · <u> </u>	is action is non-final.	•				
3)	_						
Disposit	ion of Claims	Ex parte Quayre, 1900 C.L	7. 11, 4 55 O.G. 215.				
4)⊠	Claim(s) 9-15 and 18-34 is/are pending in the	application.					
	4a) Of the above claim(s) 9-15 is/are withdrawn from consideration.						
5)⊠	Claim(s) <u>18-30</u> is/are allowed.						
6)⊠	Claim(s) <u>31 and 32</u> is/are rejected.						
7)🖂	Claim(s) 33 and 34 is/are objected to.						
	Claim(s) are subject to restriction and/o	r election requirement.					
	ion Papers						
•	The specification is objected to by the Examine						
10)	The drawing(s) filed on is/are: a) acception and acception are also acceptions.	•					
441	Applicant may not request that any objection to the The proposed drawing correction filed on						
<u> </u>	If approved, corrected drawings are required in re		sapproved by the Examiner.				
12\\[\]	The oath or declaration is objected to by the Ex	•					
,	under 35 U.S.C. §§ 119 and 120	armicr.					
-	Acknowledgment is made of a claim for foreign	n priority under 35 U.S.C. 8	3 119(a)-(d) or (f)	•			
/	☐ All b)☐ Some * c)☐ None of:	priority under 60 0.0.0.	(1) (a) (a) (b) (i).				
۵,	1.☐ Certified copies of the priority document	s have been received					
	2. Certified copies of the priority documents have been received in Application No						
	3. Copies of the certified copies of the prior			ae			
* 5	application from the International Bu See the attached detailed Office action for a list	reau (PCT Rule 17.2(a)).		3 -			
14) 🗌 A	Acknowledgment is made of a claim for domesti	c priority under 35 U.S.C.	§ 119(e) (to a provisional ap	plication).			
) The translation of the foreign language pro Acknowledgment is made of a claim for domest						
Attachmen	-						
2) Notic	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449) Paper No(s) _	5) Notice of I	Summary (PTO-413) Paper No(s) nformal Patent Application (PTO-15				

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DETAILED ACTION

Acknowledgment

1. Applicant's Response to Paper No.26 has been entered and made of Record (Paper No.27). Claims 9-15 & 18-34 are pending. However, claims 9-15, non-elected invention, are withdrawn from further consideration.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims **31-32** are rejected under 35 U.S.C. 103(a) as being unpatentable over Hur et al (Ultralinear Doubled Pulse doped AllnAs/GaAs/InP HEMTs", Electronic Lett., IEEE Stevenage, GB, Vol.32, No.16, August 1, 1996, pages 1516-1518) in view of Ando (JP08-55979).

Regarding claim **31**, Hur et al. teach a transistor, comprising (Fig.1):

a semi-insulating indium phosphide (InP) substrate; a channel layer of GaInAs disposed over the substrate layer; a Schottky layer of AlInAs disposed over the channel layer; a resistive layer (undoped-GaInAs) disposed over the Schottky layer; a contact layer (doped-GaInAs) disposed over the resistive layer, the contact layer having a first recess, and the resistive layer having a second recess; a source electrode in ohmic contact with the contact layer (doped-GaInAs); a drain electrode in ohmic contact with the contact layer; and a gate electrode in Schottky contact with the Schottky layer.

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Hur et al. do not teach the Schottky layer having a recess. However, Ando in Fig.9 teaches the Schottky layer (96) having a recess to obtain a stable device characteristic since an electric field generated by the applied voltage through the gate can be alleviated, which results in the lowered rate of impact ionization of the channel electrons. This also contributes the reduction of the parasitic capacitance between the gate and the cap layer, leading to an increase in the power gain of the device. Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to form recess in the Schottky layer as taught by Ando in the Hur's device since it contributes the reduction of the parasitic capacitance between the gate and the cap layer, leading to an increase in the power gain of the device.

Regarding-claim-32, Hur-et-al. as modified-by-Ando-teach-the-transistor-further comprising a first doped layer and a second doped layer (Si pulse).

Allowable Subject Matter

4. Claims **33-34** are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: Prior art reference, taken along or in combination, do not teach or render obvious that a ratio of silicon doping concentration approximately 2.5 to 1.5 between the first doped layer and the second doped layer or the resistive layer comprising $Al_{0.48}ln_{0.52}As$.

5. Claims **18-30** are allowed.

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The following is an examiner's statement of reasons for allowance:

Prior art reference, taken along or in combination, do not teach or render obvious that the lattice constants of the channel layer and lattice constant of the Schottky layer is different from the lattice constant of the substrate and a difference between conduction band levels of the channel and Schottky layers is larger than when the channel and Schottky layers has the same lattice constant as the substrate.

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Response to Arguments

6. Applicant's arguments with respect to claims 31-32 have been considered but are most in view of the new ground(s) of rejection.

Conclusion

-7.— Any-inquiry-concerning-this-communication or-earlier-communications from-the-examiner should be directed to Donghee Kang whose telephone number is 703-305-9147. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on 703-308-2772. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

Donghee Kang
Donghee Kang

Examiner

Art Unit 2811

dhk